

SCIENCEDOMAIN international

www.sciencedomain.org

SDI Review Form 1.6

Journal Name:	Physical Science International Journal	
Manuscript Number:	Ms_PSIJ_33788	
Title of the Manuscript:	Deposition of Silicon Films from Liquid Cyclopentasilane Precursors Using High Pressure Spray System	
Type of the Article		

General guideline for Peer Review process:

This journal's peer review policy states that <u>NO</u> manuscript should be rejected only on the basis of '<u>lack of Novelty'</u>, provided the manuscript is scientifically robust and technically sound.

To know the complete guideline for Peer Review process, reviewers are requested to visit this link:

(http://www.sciencedomain.org/page.php?id=sdi-general-editorial-policy#Peer-Review-Guideline)

SCIENCEDOMAIN international



SDI Review Form 1.6

PART 1: Review Comments

	Reviewer's comment	Author's comment (if agreed with reviewer, correct the manuscript and highlight that part in the manuscript. It is mandatory that authors should write his/her feedback here)
Compulsory REVISION comments	Author(s) should correct the mistakes in writing the chemical formular of cyclopentasilane and cyclohexasilane as written in the introduction. The following refs. were not cited in the text of the article: 13, 20. Also, refs. 21 – 38 were not reviewed. Why?	
Minor REVISION comments	As above	
Optional/General comments	Generally, the paper is fine, however it appears the organisation of the paper is rather unconventional, however, this may be due to the nature of the research carried out. I am feeling the paper should explicitly indicate in the methodology such parameters that were investigated. Yes some parameters that were used were mentioned in the methodology; however, the measured ones were not indicated. In discussing result, author(s) also mentioned on methodologies used. I think discussion should just be on explaining results obtained, and how these align with other bodies of knowledge in the literature.	

Reviewer Details:

Name:	Victor A. Adedayo
Department, University & Country	Institute of Technology, Ilorin, Nigeria